



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/756,409	01/14/2004	Hiroataka Kawata	118006	2629

25944 7590 12/16/2005

OLIFF & BERRIDGE, PLC
P.O. BOX 19928
ALEXANDRIA, VA 22320

EXAMINER

LE, THAO X

ART UNIT PAPER NUMBER

2814

DATE MAILED: 12/16/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	10/756,409	KAWATA ET AL.	
	Examiner	Art Unit	
	Thao X. Le	2814	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
 - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
 - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
 - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 15 July 2005.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-16 is/are pending in the application.
- 4a) Of the above claim(s) 6,7 and 12-14 is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-5,8-11,15 and 16 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| Paper No(s)/Mail Date <u>11/07/05,10/21/05</u> . | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 15 Nov. 2005 has been entered.

Claim Objections

2. Claim 1 objected to because of the following informalities: 'monocrystalline semiconductor layer that at other portions' line 10 and 'on the 0thermal oxide film' line 11 of claim 1 should read 'monocrystalline semiconductor layer than that at other portions' and 'on the thermal oxide film', respectively. Appropriate correction is required.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

Art Unit: 2814

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

4. Claims 1-5, 8-11 and 15 are rejected under 35 U.S.C. 102(e) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over US 6528358 to Yamazaki et al.

Regarding claim 1, Yamazaki discloses a transistor in fig. 23E, comprising: a monocrystalline semiconductor layer 41, column 44 line 32 and col. 47 lines 13-25, including a channel region 52, column 45 line 31, a lightly doped region 50, column 45 line 25, and a heavily doped region 49, column 45 line 16, the monocrystalline semiconductor layer 41 having a surface, a side extending substantially perpendicular to the surface, fig. 23A, and a shoulder (corner of layer 41) portion disposed where the surface and the side intersect, fig. 23A, and a gate insulating film 38/42 provided over the monocrystalline semiconductor layer 41, the gate insulating film having a thermal oxide film 38, column 44 line 33, formed on the monocrystalline semiconductor layer 41, the thermal oxide film being thinner at a portion corresponding to the shoulder portion of the monocrystalline semiconductor layer 41 than that at other portions, and at least one vapor-deposited insulating film 42, column 44 line 38, formed on the thermal oxide film 38, fig. 23B, the at least one vapor-deposited insulating film 42 covering an area including at least the channel region 52, the lightly doped region 50, and the heavily doped region 47 of the monocrystalline semiconductor layer 41, fig. 23E, the at least one vapor-deposited insulating film having a thickness at the shoulder portion of the

monocrystalline semiconductor layer 41 that is substantially equal to that at other portions, fig. 23E.

With respect to 'the thermal oxide film being thinner at a portion corresponding to the shoulder portion of the monocrystalline semiconductor layer 41 that at other portions' and 'the at least one vapor-deposited insulating film having a thickness at the shoulder portion of the monocrystalline semiconductor layer 41 that is substantially equal to that at other portions', Yamazaki discloses the oxide layer 38 and vapor-deposited layer 42 that are substantially identical to that of the claims, claimed properties or functions are presumed to be inherent. Or where the claimed and prior art products are identical or substantially identical in structure or composition, or are produced by identical or substantially identical processes, a *prima facie* case of either anticipation or obviousness has been established. *In re Best*, 195 USPQ 430, 433 (CCPA 1977) and MPEP 2112.01. Furthermore, the Applicant Admitted Prior Art (AP) confirms the thinner portion 41a of a thermal oxide layer 41 at a shoulder of a monocrystalline semiconductor 40 in fig. 15.

Regarding claim 2, Yamazaki discloses the transistor according to claim 1, the monocrystalline semiconductor layer 38 being made of monocrystalline silicon, column 44 line 33 and discussion in claim 1 above.

Regarding claim 3, Yamazaki discloses the transistor according to claim 1, the monocrystalline semiconductor layer 38 being a mesa type, Fig. 23A.

Regarding claim 4, Yamazaki discloses the transistor according to claim 1, the monocrystalline semiconductor layer 38 having a thickness of 50 nm, column 33 line 11.

Regarding claim 5, Yamazaki discloses the transistor according to claim 1, the thermal oxide film 38 of the gate insulating film having a thickness of 50 nm, column 33 line 18.

Regarding claims 8-11 and 15, Yamazaki discloses an electro-optical device, comprising: a transistor, fig. 23E, wherein a transistor according to claim 1 being provided as a switching element in a display area, fig. 60F, a electro-optical device, fig. 60E, a semiconductor device, 23E.

In the recitation 'an electro-optical device' and 'an electronic apparatus' has not been given patentable weight because it have been held that a preamble is denied the effect of a limitation where the claim is drawn to a structure and the portion of the claim following the preamble is a self-contained description of the structure not depending for completeness upon the introductory clause. *Kropa v. Robie*, 88 USPQ 478(CCPA 1951).

Claim Rejections - 35 USC § 103

5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

6. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

7. Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over US 6528358 to Yamazaki et al. in view of US 6653657 to Kawasaki et al.

Regarding claim 16, Yamazaki discloses the transistor comprising the monocrystalline semiconductor layer 41 further having a storage capacitor electrode portion 49 that includes the shoulder portion, the thermal oxide film 38 and the vapor-deposited insulating 42 being interposed on the capacitor electrode portion 49 and serving as a dielectric, fig. 23E.

But Yamazaki does not disclose the transistor further comprising: a capacitor line.

However, Kawasaki discloses a transistor comprising a capacitor line 235, fig. 10D, the semiconductor layer 208, fig. 9A, further having a storage capacitor electrode portion 221, fig. 10A col. 11 line 17, the oxide film 222, fig. 10B col. 11 line 37, being interposed between the capacitor line 235 and the storage capacitor electrode portion 221 and serving as a dielectric, fig. 10D. At the time

the invention was made; it would have been obvious to one of ordinary skill in the art to use the storage capacitor teaching of Kawasaki with Yamazaki's device, because it would have improved the operation performance and reliability of a semiconductor device as taught by Kawasaki in column 15 lines 34-40.

Response to Arguments

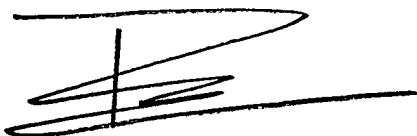
8. Applicant's arguments filed 15 Nov. 2005 have been fully considered but they are not persuasive. The Applicant argues that the crystal silicon film of Yamazaki is not a monocrystalline semiconductor. The Examiner respectfully disagrees because the crystal silicon of Yamazaki is being referred to as a silicon film having a crystallinity, col. 1 line 28. In addition, Yamazaki clearly discloses the crystal silicon is a mono-crystal domain having a substantially mono-crystal domain, col. 47 lines 18-25 and col. 60 lines 60-65.

Conclusion

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thao X. Le whose telephone number is (571) 272-1708. The examiner can normally be reached on M-F from 8:00 AM - 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M. Fahmy can be reached on (571) 272 -1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

A handwritten signature in black ink, appearing to be 'Thao X. Le', with a stylized, sweeping horizontal stroke at the end.

Thao X. Le
Patent Examiner
06 December 2005